Experimental Verification of Van Vleck Nature of Long-Range Ferromagnetic Order in Vanadium-Doped Three-Dimensional Topological Insulator Sb₂Te₃

 $\begin{array}{c} \mbox{Mingda Li1,2^*}$, Cui-Zu Chang2^*}$, Lijun Wu3, Jing Tao3, Weiwei Zhao6, Moses H. W. Chan6, Jagadeesh S. \\ \mbox{Moodera}$^{2.5}$, Ju Li1,4, and Yimei Zhu3^*} \end{array}$

¹Department of Nuclear Science and Engineering, Massachusetts Institute of Technology, Cambridge, MA 02139, USA
²Francis Bitter Magnet Lab, Massachusetts Institute of Technology, Cambridge, MA 02139, USA

We demonstrate by high resolution low temperature electron energy loss spectroscopy (EELS) measurements that the long range ferromagnetic (FM) order in vanadium (V)-doped topological insulator Sb_2Te_3 has the nature of van Vleck-type ferromagnetism. The positions and the relative amplitudes of two core-level peaks (L_3 and L_2) of the V EELS spectrum show unambiguous change when the sample is cooled from room temperature to T=10K. Magnetotransport and comparison of the measured and simulated EELS spectra confirm that these changes originate from onset of FM order. Crystal field analysis indicates that in V-doped Sb_2Te_3 , partially filled core states contribute to the FM order. Since van Vleck magnetism is a result of summing over all states, this magnetization of core level verifies the van Vleck-type ferromagnetism in a direct manner.

PACS: 73.20.-r, 75.50.Pp, 79.20.Uv.

The breaking of time-reversal symmetry (TRS) and opening of surface bandgap of topological insulator (TI) is an essential step towards observing other quantum states [1-3]. When the TI's chiral Dirac surface state is gapped, a number of promising novel phenomena could be realized, including quantum anomalous Hall effect (QAHE) [3-10] where spontaneous magnetization and spin-orbit coupling lead to a topologically nontrivial electronic structure, and topological magneto-electric effect results through coupling between electric field and spin texture, which can potentially lead to low-power electrically-controlled spintronic devices [11-15]. There are two generic approaches to break the TRS: by magnetic proximity effect or by conventional transition metal (TM) doping [1, 16]. Doping TM impurities(i.e. V, Cr, Mn) into TI can induce a perpendicular ferromagnetic (FM) anisotropy, providing a straightforward method to open up the bandgap of the TI's chiral surface state and tune the corresponding transport properties [7, 8, 17-21]. In diluted magnetic semiconductors (DMSs) doped with TM atoms, the induced FM order in general originates from itinerant charge carriers [22, 23], i.e. Ruderman-Kittel-Kasuya-Yosida (RKKY)-mediated FM order. However, in magnetically doped TI, the itinerant carriers may destroy the QAHE by providing additional conduction channels [24], resulting in a leakage current [12, 25], which severely hinders magnetic TI for device applications. Therefore, a carrier-free yet long range mechanism to induce FM order

in magnetically doped TI is highly desirable for progress towards device applications.

On the other hand, in magnetically doped TI, the firstprinciple calculations predicted that the insulating magnetic ground state can indeed be obtained by a proper choice of TM dopants, through van Vleck-type ferromagnetism in the absence of itinerant carriers [5]. Recently, Chang et al. [7, 8] has reported experimental observation of QAHE in magnetic TI Cr- and V-doped (Bi,Sb)₂Te₃, where the insulating FM order [21] excludes the RKKY-type interaction and indicates the FM mechanism to be of van Vleck-type as first-principle calculations predicted. In such a system, the inverted band structure in TI leads to the large matrix element of valence band [5, 21, 24], dramatically increasing the contribution to spin susceptibility. Since the van Vleck-type susceptibility is directly related with 2^{nd} order energy perturbation [26], one could understand the van Vleck-type mechanism qualitatively from 2nd order perturbation theory, as shown in eq. (1),

$$E_0^{(2)} = \sum_{n} \frac{\left| \left\langle 0 \left| \mu_{\rm B}(\vec{L} + g\vec{S}) \cdot H \left| n \right\rangle \right|^2}{E_0 - E_n}$$
 (1)

Here, \sum denotes the summation over all partially filled states. In this sense, the matrix element $\left|\left\langle 0\left|\mu_{\rm B}(\vec{L}+g\vec{S})\cdot H\left|n\right\rangle\right|\right|$ when n becomes valence band is

Condensed Matter Physics & Materials Science Department, Brookhaven National Laboratory, Upton, NY 11973, USA
 Department of Material Science and Engineering, Massachusetts Institute of Technology, Cambridge, MA 02139, USA
 Department of Physics, Massachusetts Institute of Technology, Cambridge, MA 02139, USA

⁶ The Center for Nanoscale Science and Department of Physics, The Pennsylvania State University, University Park, PA 16802-6300, USA

maintaining the data needed, and c including suggestions for reducing	lection of information is estimated to completing and reviewing the collect this burden, to Washington Headqu uld be aware that notwithstanding ar DMB control number.	ion of information. Send comments arters Services, Directorate for Information	regarding this burden estimate or mation Operations and Reports	or any other aspect of the property of the pro	nis collection of information, Highway, Suite 1204, Arlington		
1. REPORT DATE 2015	2 DEDORT TYPE			3. DATES COVERED 00-00-2015 to 00-00-2015			
4. TITLE AND SUBTITLE	5a. CONTRACT NUMBER						
Experimental Veri Ferromagnetic Ord	5b. GRANT NUMBER						
Topological Insulator Sb2Te3					5c. PROGRAM ELEMENT NUMBER		
6. AUTHOR(S)	5d. PROJECT NUMBER						
	5e. TASK NUMBER						
		5f. WORK UNIT NUMBER					
7. PERFORMING ORGANI Massachusetts Inst and Engineering, C	8. PERFORMING ORGANIZATION REPORT NUMBER						
9. SPONSORING/MONITO	10. SPONSOR/MONITOR'S ACRONYM(S)						
	11. SPONSOR/MONITOR'S REPORT NUMBER(S)						
12. DISTRIBUTION/AVAII Approved for publ	LABILITY STATEMENT ic release; distributi	on unlimited					
13. SUPPLEMENTARY NO Accepted by Phys.							
14. ABSTRACT							
15. SUBJECT TERMS							
16. SECURITY CLASSIFIC	17. LIMITATION OF ABSTRACT	18. NUMBER OF PAGES	19a. NAME OF				
a. REPORT unclassified	b. ABSTRACT unclassified	c. THIS PAGE unclassified	Same as Report (SAR)	5	RESPONSIBLE PERSON		

Report Documentation Page

Form Approved OMB No. 0704-0188 huge, and contributes significantly to the spin susceptibility. On the other hand, eq. (1) also tells us that there are additional contributions from other partially filled states, enabling us to adopt a more direct approach to experimentally prove the van Vleck-type ferromagnetism without the carrier dependence, where electronic states in addition to itinerant electrons will contribute to FM order.

In this Letter, we report the magnetization of partially filled Vanadium (V) $2p_{3/2}$ and $2p_{1/2}(L_3$ and L_2) core states, using low-temperature high-resolution Electron Energy Loss Spectroscopy (EELS). The condition for partial filling of core states is achieved when a high-energy incidence of electrons on a sample in a transmission electron microscope (TEM) excites a core electron to unoccupied states leaving a core-hole behind, giving to the energy-loss spectrum. Analyzing the fine structure of the energy-loss spectrum provides not only the information on the unoccupied local density of states, but also angular momentum, spin and chemical nature of the element. We find that by comparing with room temperature (RT) spectrum, the Te $M_{4.5}$ edge at T=10K shows no shift, while the V L_3 and L_2 peaks show a red shift as large as 0.6eV. In addition, there is a clear drop of L_3/L_2 peak intensity ratio. EELS simulation with FEFF 9.6 [27-29] shows that such a shift is a signature of onset of FM, which is independently verified through magneto-transport results, which shows anomalous Hall effect below the Curie temperature *T*_C~70K.

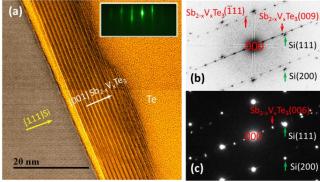


FIG. 1 (color online). (a) High-resolution image of the V-doped Sb₂Te₃ sample S3 grown on etched Si substrate (bottom-left, brown region) viewed along $[\overline{110}]$ of Sb_{2-x}V_xTe₃. Another capping layer (top-right, yellow region) is mainly composed of amorphous Te protection layers. The upper left inset is a reflection high-energy electron diffraction (RHEED) image showing the ultrahigh crystalline quality of the MBE-grown film. (b) Diffractogram from (a). One set of spots as indicated by green arrows can be indexed as $(\overline{011})^*$ pattern of Si, while the other set of spots indicated by red arrows can be indexed as $(\overline{110})^*$ pattern of a rhombohedral lattice with a=0.42 nm and c=3.03 nm which is basically the same as Sb₂Te₃ lattice, indicating negligible influence of V-dopants to the lattice. The [001] Sb₂Te₃ is slightly misaligned (~3°) with [111] Si (c) Select-area electron diffraction pattern from the area containing both film and substrate.

High-quality V-doped Sb₂Te₃ films are grown by molecular beam epitaxy (MBE) under a base vacuum $\sim 5 \times 10^{-10}$ Torr, where thin film Sb₂Te₃ (111) was grown on top of etched Si (111) substrates with V-dopants coevaporated from an electron beam source during TI growth. Ultrathin cross sectional TI film samples are fabricated through focused ion beam and post processing for high-resolution TEM studies. The EELS measurements were carried out using the doubled aberration corrected JEM-ARM200CF TEM, equipped with a cold fieldemission gun and the state-of-the-art duel energy-loss spectrometer (Quantum GIF). V-doped Sb₂Te₃ samples still maintain a very good layered structure (Fig.1a), due to the likely case that V dopants tend to substitute Sb sites instead of creating interstitials [7]. The selected area electron diffraction (SAD) pattern (Fig. 1b) along [0001] zone-axis direction also verifies negligible influence of V-dopants to the crystal structure, in that the V-doped Sb₂Te₃ has almost identical lattice constant compared with that of pure Sb₂Te₃.

Fig. 2 shows the main result of this *Letter* comparing with the EELS spectra in the high-loss region at RT and low temperature T=10K. A simultaneous collection of both low-loss and high-loss spectra allows for a high-accuracy positioning of zero-loss peak thus accurate energy scale calibration. We see clearly that the $M_{4,5}$ edge of the Te element does not shift with temperature, while there are obvious peak position shifts (>0.5eV) for both V L_3 and L_2 peaks, accompanied with a decrease in L_3/L_2 ratio.

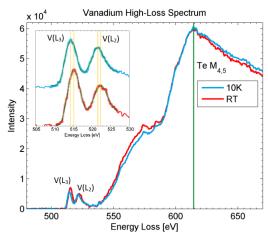


FIG. 2 (color online). EELS spectra of V L and Te $M_{4,5}$ edges at RT (red curve) and 10 K (blue curve) for sample S2, normalized with Te $M_{4,5}$ edge intensity. The energy position of Te $M_{4,5}$ edge is invariant as temperature (green line), while there is a clear redshift of vanadium's L_3 and L_2 positions (yellow lines) and a drop of L_3/L_2 ratio. The energy scale has been accurately calibrated by simultaneously acquiring and aligning of the zero-loss peak.

In order to verify the observed peak shift, we measured three samples of $Sb_{2-x}V_xTe_3$ with different V concentrations and thicknesses, namely sample S1: 20 quintuple layer (QL) with x=0.08; S2: 20QL with x=0.16

and S3: 12 QL with x=0.08. The corresponding mean V-V distances in all the samples are thus \geq 10 nm. Since EELS is a spatially highly localized probe and there might be small non-uniformity of dopants, we collected 8 spectra at both 10K and RT for each sample to reduce the measurement uncertainty. Furthermore, we use two different algorithms to extract the peak positions. The averaged V L_3 and L_2 peak positions and L_3/L_2 ratios for all the three samples are plotted in Figs. 3 (b-d).

All three samples show the same trend that the L_3 and L_2 peak positions at T=10K (blue and green dots in Figs. 3b and c) undergo a redshift compared with RT (red and purple dots). For L_2 peaks, all three samples shift similar amounts ~0.4eV, while for L_3 peak positions, the shift ranges from 0.3eV (samples S1 and S3) to 0.7eV (sample S2). This indicates that at low temperature, certain mechanism which does not change Te states alters the L_3 and L_2 core states of V. The higher concentration of V tends to yield a stronger energy reduction of L_3 peaks. In addition, the L_3/L_2 ratio drops from ~1.4 to 1.1 (samples S2 and S3), indicating a possible change of electronic structure or even a phase transition [30].

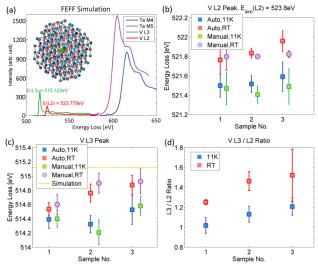


FIG. 3 (color online). (a) FEFF simulation of the high-loss EELS spectrum of V-doped Sb₂Te₃, using a nanosphere (inset) with a scattering center in the middle. (b-d) Experimental EELS peak positions and shifts. (b) The V- L_2 peak positions, showing similar trend of redshift for all three samples. The two algorithms show consistent results (c) The V- L_3 peak positions, where sample S2 with highest V-concentration shows highest redshift. A horizontal yellow line marks the energy position from non-magnetic simulation, which is slightly higher than the RT magnitudes. (d) The V's L_3/L_2 peak intensity ratio change. At T=10K, the ratio drops, which is also consistent with the simulation, where for non-magnetic system the ratio is even higher.

To understand the possible origin of the peak position shift and peak intensity ratio drop, we simulate the EELS spectrum with a non-magnetic V-doped TI nanosphere using FEFF9 (Fig. 3(a) inset). We take 1.0nm for full

multiple scattering cutoff radius and 0.5nm for self-consistent-field cutoff radius to ensure convergence, with Hedin-Lundqvist self-energy and random phase approximation with core-hole correction. The resulting non-magnetic peak positions give $E(L_3)$ =515.1eV and $E(L_2)$ =523.8eV, which are both higher than the magnitude at RT. The higher V energy for a non-magnetic system is quite reasonable, since even at RT, there is already partial magnetization due to the field in the sample areas from the objective lens of the microscope. In other words, the redshift of V L_3 and L_2 peaks is consistent with a picture that non-magnetic system has even higher energy.

As shown in Fig. 3, the different amount of redshift for L_3 and L_2 edges is consistent with a temperature-independent Te $M_{4,5}$ position at ~615eV. Sample S2 with highest V concentration (x=0.16) shows the highest redshift, indicating that such redshift has an origin related to strong V-V interaction. Moreover, since the L_3 and L_2 has similar order of peak positions (around 515eV and 521eV), but different l-s spin coupling configuration, the different redshift amount between L_3 and L_2 peaks further indicates that a spin-related process may play an important role in the V-V interaction.

Thus, the consistently observed trend at RT and T=10Kof the energy redshift of V's L_3 and L_2 edge and the decrease of L_3/L_2 ratio from non-magnetic simulations unambiguously indicates a change of electronic structure, while the very different redshift behavior between L_3 and L_2 peak together with a concentration dependence further indicating a magnetic origin from these core levels. Actually, this core-level magnetism for V-dopants could also be understood through crystal field theory. For an l=2transition metal ion dopant (such as V), the character table of irreducible representation for full rotational group is shown in Table 1. The conjugacy classes are taken as the symmetry elements contained in TI's D_{3d} group. Under TI's rhombohedral D_{3d} crystal field, this irreducible representation $\Gamma^{(2)}_{full}$ becomes reducible, resulting in the lift of degeneracy and crystal field splitting.

χ	E	2C ₃	3C' ₂	I	2S ₆	$3\sigma_{\scriptscriptstyle d}$
$\Gamma^{(2)}_{\mathit{full}}$	5	-1	+1	5	-1	+1

Table 1. Character table of irreducible representation $\Gamma_{full}^{(2)}$ for the full rotational group. When crystal field is present, this becomes a reducible presentation and the degeneracy is lifted.

From Table 1 and character table of D_{3d} group [31], we calculate the decomposition of the representation $\Gamma_{full}^{(2)}$ in D_{3d} group as:

$$\Gamma_{full}^{(2)} = A_{1g} \oplus 2E_g \tag{2}$$

i.e. instead of splitting to a 2-fold E_g and a 3-fold T_{2g} level which is the case of octahedral crystal field, an l=2 transition metal ion would split from a 5-fold level to two 2-fold levels (E_g and E'_g) and one non-degenerate level A_{Ig} (Fig. 4) under TI's rhombohedral crystal field.

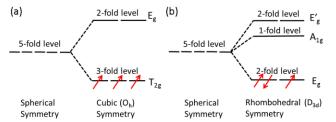


FIG. 4 (color online). (a) Crystal field splitting in cubic crystal field. T_{2g} levels allow the spin alignment from all three 3d electrons of V (red arrows), leading to a possible FM order. (b) Crystal field splitting under rhombohedral D_{3d} crystal field. Since the energy only splits into a 2-fold level and only 1 electron has unpaired spin it is too weak to form a FM order.

Since V has electron configuration [Ar] $3d^34s^2$, this crystal field effect tends out to be important to explain why sole V's 3d electron states may not be sufficient to form FM order in TI. Unlike cubic crystal field where a 3-fold T_{2g} state allows a parallel spin configuration (Fig. 4a), the 2-fold E_g level and Pauli's exclusion principle only lead to single unpaired electron under rhombohedral crystal field. This becomes too weak to form a long range FM order by solely 3d valence states (Fig. 4b). Therefore, the FM order in V-doped TI may be mediated from other V-states, such as core states. This is fully consistent with our EELS results for L_3 and L_2 core states at T=10K.

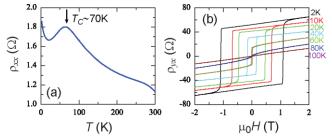


FIG. 5 (color online). (a) Longitudinal resistance ρ_{xx} as a function of temperature at zero-field. (b) Magnetic-field dependent Hall resistance ρ_{yx} . The hysteresis loop below ~70K is indicating an FM order.

In order to further demonstrate that the V-doped Sb_2Te_3 system is indeed FM at T=10K, we perform

[1] X. L. Qi and S. C. Zhang, Reviews of Modern Physics **83**, 1057 (2011).

[2] M. Z. Hasan and C. L. Kane, Reviews of Modern Physics **82**, 3045 (2010).

magnetotransport measurement for both longitudinal and transverse directions. Temperature-dependent longitudinal dc resistivity at zero magnetic field shows a resistivity hump at about 70K, indicating the onset of FM order (Fig. 5a). Figure 5b shows the hysteresis loop of the Hall resistance ρ_{yx} . The loop is closed above 70K, which is consistent with the ρ_{xx} result. Hence we conclude that the Curie temperature T_c to be ~70K, far above the EELS measurement temperature T=10K. This independently verifies the FM order of our V-doped Sb₂Te₃ sample.

In conclusion, we have demonstrated the van Vleck nature of FM order in V-doped TI Sb₂Te₃ using lowtemperature high resolution EELS. An energy redshift is observed in V's L_3 and L_2 core states, which could be understood as a signature due to the onset of FM order, while the FM order itself is shown independently through magnetotransport measurement. The V-dopants' core-level contribution to the ferromagnetism in TI is thus in sharp contrast to the RKKY-type ferromagnetism, where only itinerant electrons contribute to the magnetic susceptibility regardless the core level states, but consistent with the picture of van Vleck-type ferromagnetism, where the susceptibility is a summation of contribution from all possible intermediate states. In this sense, although we could not exclude the contribution of RKKY interaction to the FM order from the band electrons, van Vleck mechanism, resulting from core levels and playing significant role in FM order, is observed unambiguously. Such a core-level contribution could also be understood from a crystal-field perspective, where three 3d electrons under rhombohedral crystal field could neither lead to FM order nor screen the contribution from the cores.

The work at the Brookhaven National Laboratory was supported by the U.S. Department of Energy, Office of Basic Energy Sciences under Contract No. DE-AC02-98CH10886. J.S.M. and C.Z.C would like to thank support from the STC Center for Integrated Quantum Materials under NSF grant DMR-1231319, NSF DMR grants 1207469 and ONR grant N00014-13-1-0301. Work at Penn State was supported by NSF MRSEC program under award numbers DMR-0820404 and DMR-1420620.

* Authors to whom correspondence should be addressed: mingda@mit.edu (M. L.); czchang@mit.edu (C. Z. C.); zhu@bnl.gov (Y. Z.).

[3] C.-Z. Chang, P. Wei, and J. S. Moodera, MRS Bulletin **39**, 867 (2014).

[4] X. L. Qi, T. L. Hughes, and S. C. Zhang, Phys Rev B **78**, 195424 (2008).

[5] R. Yu, et al., Science **329**, 61 (2010).

- [6] C.-X. Liu, X.-L. Qi, X. Dai, Z. Fang, and S.-C. Zhang, Phys Rev Lett **101**, 146802 (2008).
- [7] C. Z. Chang et al., Submitted.
- [8] C. Z. Chang et al., Science **340**, 167 (2013).
- [9] X. F. Kou *et al.*, Phys Rev Lett **113**, 137201 (2014).
- [10] J. G. Checkelsky, et al., Nat Phys 10, 731 (2014).
- [11] A. M. Essin, J. E. Moore, and D. Vanderbilt, Phys Rev Lett **103**, 146805 (2009).
- [12] L. A. Wray, Nat Phys 8, 705 (2012).
- [13] R. D. Li, J. Wang, X. L. Qi, and S. C. Zhang, Nat Phys **6**, 284 (2010).
- [14] F. X. Xiu *et al.*, Nature Nanotechnology **6**, 216 (2011).
- [15] O. V. Yazyev, J. E. Moore, and S. G. Louie, Phys Rev Lett **105**, 266806 (2010).
- [16] P. Wei, et al., Phys Rev Lett **110**, 186807 (2013).
- [17] S. Y. Xu et al., Nat Phys 8, 616 (2012).
- [18] Y. L. Chen et al., Science **329**, 659 (2010).
- [19] Y. S. Hor et al., Phys Rev B 81, 195203 (2010).
- [20] C. Z. Chang *et al.*, Phys Rev Lett **112**, 056801 (2014).
- [21] C. Z. Chang et al., Adv Mater 25, 1065 (2013).

- [25] J. W. Liu, et al., Nat Mater 13, 178 (2014).
- [26] R. M. White, *Quantum theory of magnetism:* magnetic properties of materials (Springer, Berlin; New York, 2007), 3rd, completely rev. edn., Springer series in solid-state sciences..
- [27] J. J. Rehr, *et al.*, Phys Chem Chem Phys **12**, 5503 (2010).
- [28] K. Jorissen, J. J. Rehr, and J. Verbeeck, Phys Rev B **81**, 155108 (2010).
- [29] J. J. Rehr et al., Cr Phys 10, 548 (2009).
- [30] R. F. Egerton, *Electron energy-loss spectroscopy in the electron microscope* (Plenum Press, New York, 1996), 2nd edn., The language of science.
- [31] M. S. Dresselhaus, G. Dresselhaus, and A. Jorio, *Group theory : application to the physics of condensed matter* (Springer-Verlag, Berlin, 2008).

^[22] H. Ohno, et al., Nature 408, 944 (2000).

^[23] T. Dietl, Nat Mater **9**, 965 (2010).

^[24] K. He, Y. Wang, and Q. K. Xue, National Science Review 1, 38 (2013).